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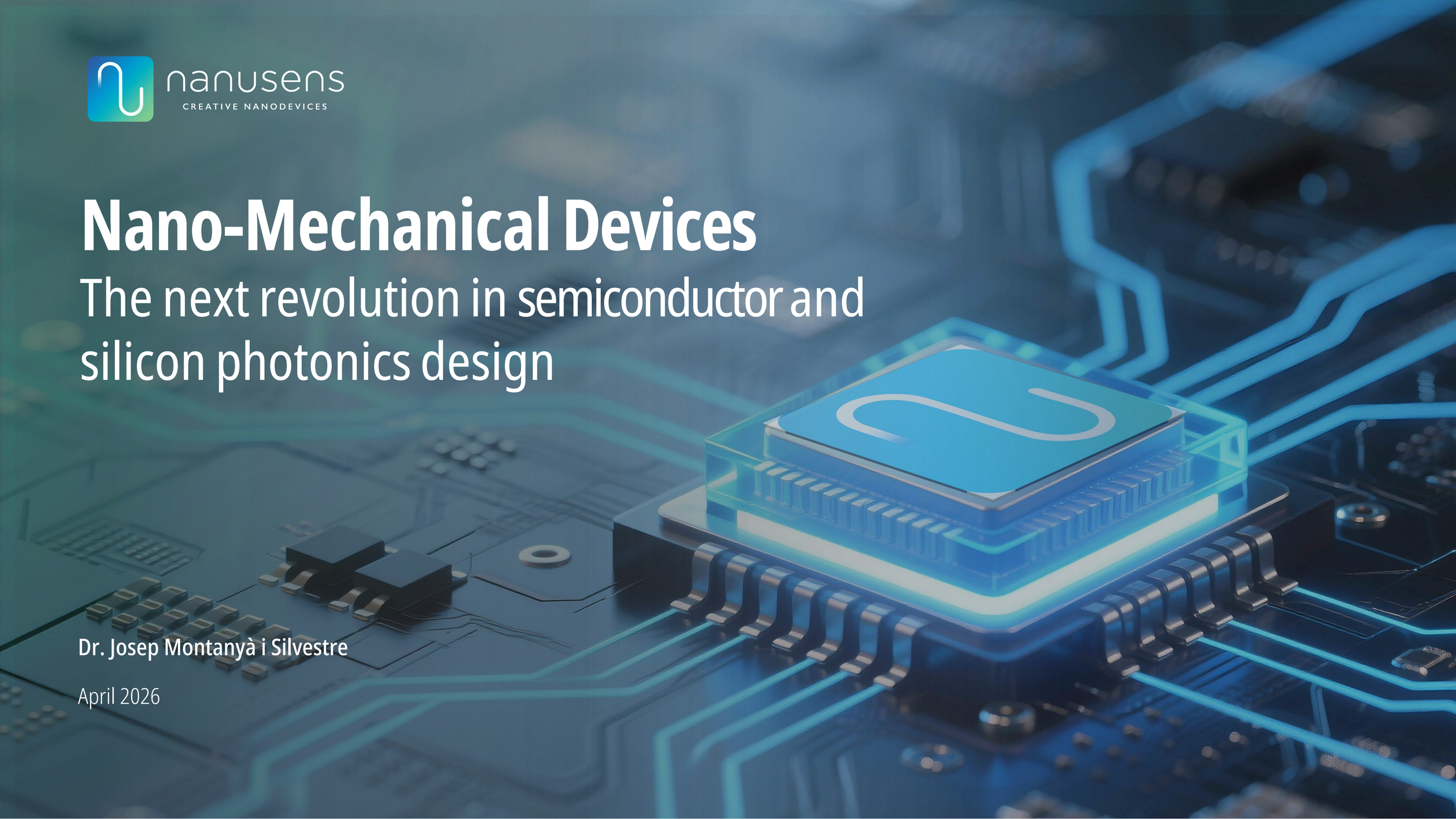
CREATIVE NANODEVICES

Nano-Mechanical Devices

The next revolution in semiconductor and silicon photonics design



Dr. Josep Montanyà i Silvestre

April 2026

PROBLEM:

No manufacturing standard for MEMS

- Limited economy of scale
- Stand alone Integrated Circuit
- Cannot meet the cost, performance, size & volume production requirements the market is demanding

SOLUTION:

Use solid state manufacturing (CMOS & Si photonics)

- Large economy of scale
- Embedded MEMS (e-MEMS)
- Unique levels of low cost, high performance, miniaturization and virtually unlimited volume production capability

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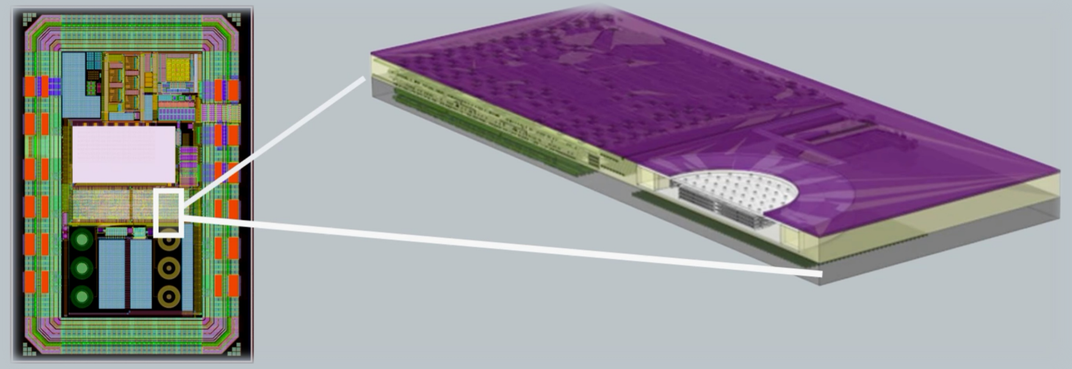
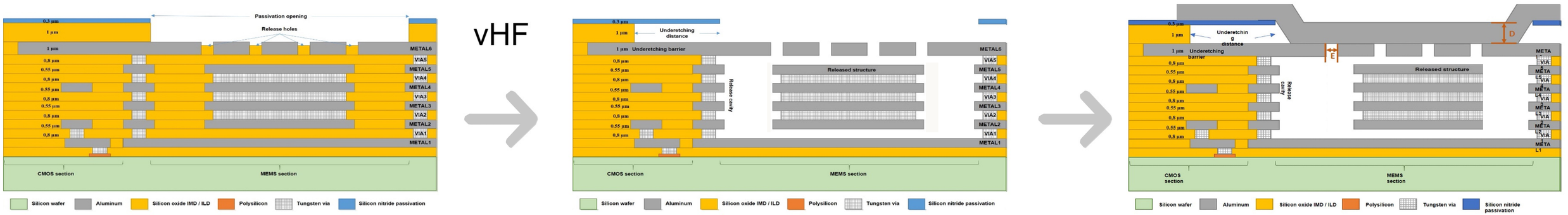
SECRET SAUCE: ONE POST-PROCESSING STEP
+ UNIQUE DESIGNS

- We use the metal layers existing into the CMOS die to implement the MEMS devices.
- We use vHF (Hydrofluoric Acid in vapour stage) to etch away some silicon oxide, creating a MEMS cavity.
- It is a maskless and short process, using standard equipment which has been qualified and used by major MEMS wafer fabs globally.
- Optionally we seal using standard process without additional equipments or materials required.

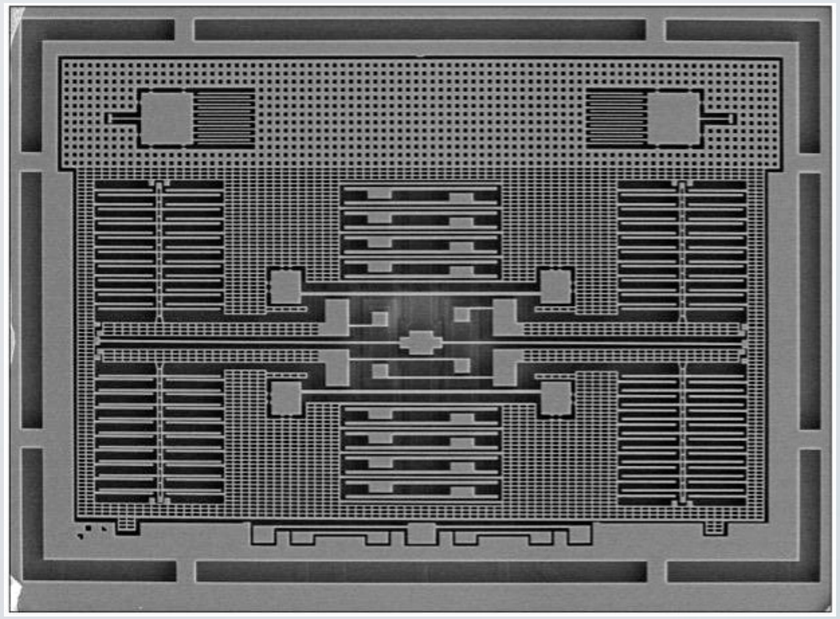




NANUSENS BREAKS THE SIZE AND PERFORMANCE BARRIER

Competitor's micro-mechanical device

740 µm

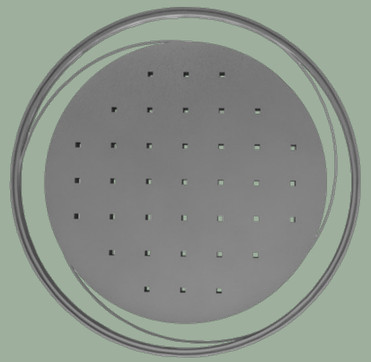


510 µm

Next generation devices need smaller, faster, lower energy and higher sensitivity chips. Current manufacturing technology cannot meet these demands.

Nanusens technology: +100x smaller

90 µm (Now) 5 µm (2030)



Single-chip solution

Create 3D mechanical devices on the microchip itself.
No need for complex multi-die packages

Nano-mechanical devices built using standard manufacturing process
No need of low-volume proprietary manufacturing processes

Leveraging the latest advances in semiconductor manufacturing 100nm feature sizes and beyond
+10x smaller than what is possible today

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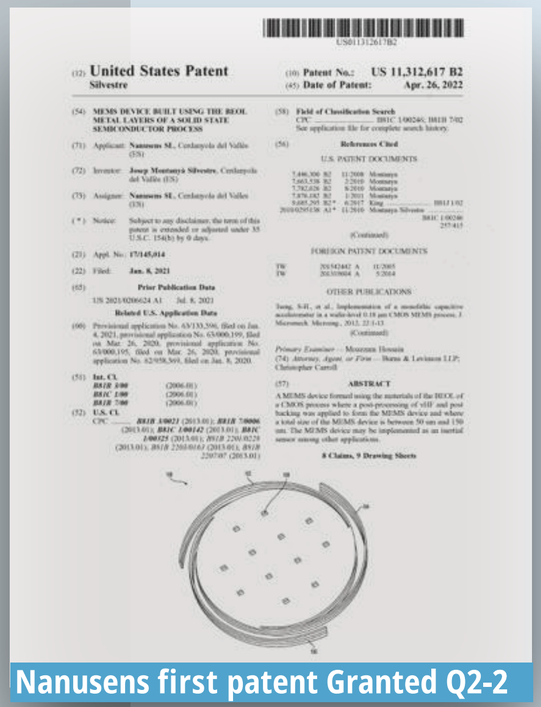
PATENT PORTFOLIO

Blocking all useful MEMS built in CMOS BEOL

- More than 100 inventions packed in multiple patents
- 10 patents granted, first one in Q2 2022
- 53 patents filed, grouped in 12 patent families and more coming
- Boston Galway (Boston) as patent attorneys
- Useful MEMS = performance, yield, Quality & Reliability, standard packaging



US011312617B2

(12) **United States Patent**
Silvestre

(10) **Patent No.: US 11,312,617 B2**
(45) **Date of Patent: Apr. 26, 2022**

(54) **MEMS DEVICE BUILT USING THE BEOL METAL LAYERS OF A SOLID STATE SEMICONDUCTOR PROCESS**

(71) Applicant: **Nanusens SL**, Cerdanyola del Vallès (ES)

(72) Inventor: **Josep Montanyà Silvestre**, Cerdanyola del Vallès (ES)

(73) Assignee: **Nanusens SL**, Cerdanyola del Vallès (ES)

(*) Notice: Subject to any disclaimer, the term of this patent is extended or adjusted under 35 U.S.C. 154(b) by 0 days.

(21) Appl. No.: **17/145,014**

(22) Filed: **Jan. 8, 2021**

(65) **Prior Publication Data**

US 2021/0206624 A1 Jul. 8, 2021

Related U.S. Application Data

(60) Provisional application No. 63/133,596, filed on Jan. 4, 2021, provisional application No. 63/000,199, filed on Mar. 26, 2020, provisional application No. 63/000,195, filed on Mar. 26, 2020, provisional application No. 62/958,569, filed on Jan. 8, 2020.

(51) **Int. Cl.**
B81B 3/00 (2006.01)
B81C 1/00 (2006.01)
B81B 7/00 (2006.01)

(52) **U.S. Cl.**
CPC ***B81B 3/0021*** (2013.01); ***B81B 7/0006*** (2013.01); ***B81C 1/00142*** (2013.01); ***B81C 1/00325*** (2013.01); *B81B 2201/0228* (2013.01); *B81B 2203/0163* (2013.01); *B81B 2207/07* (2013.01)

(58) **Field of Classification Search**
CPC B81C 1/00246; B81B 7/02
See application file for complete search history.

(56) **References Cited**

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(Continued)

Primary Examiner — Mouzam Hossain
(74) *Attorney, Agent, or Firm* — Ibarra & Levinson LLP; Christopher Carroll

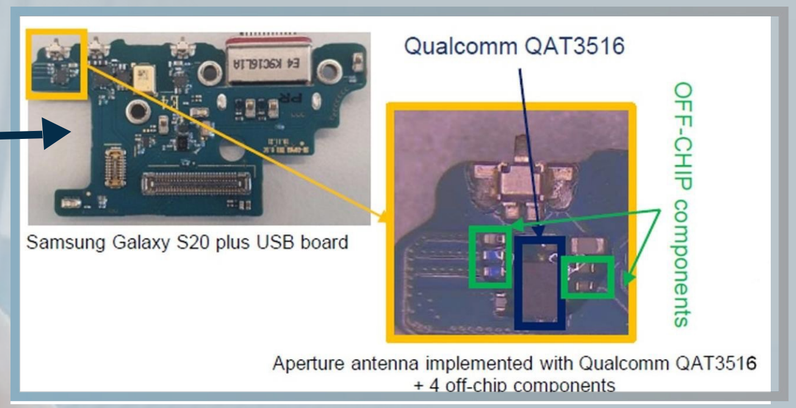
(57) **ABSTRACT**

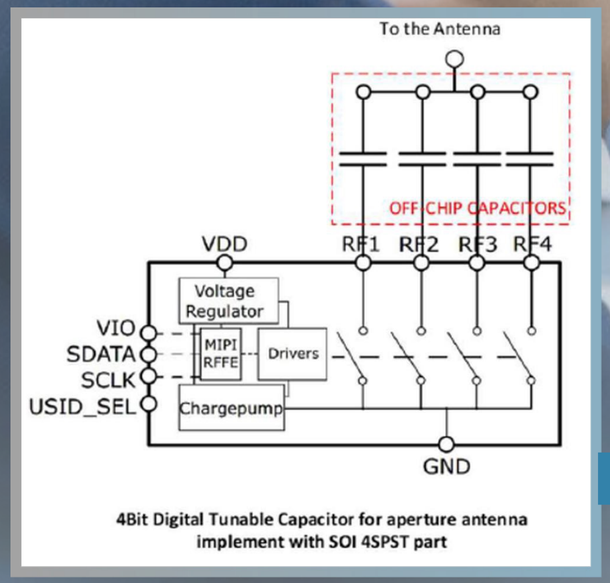
A MEMS device formed using the materials of the BEOL of a CMOS process where a post-processing of vHF and post backing was applied to form the MEMS device and where a total size of the MEMS device is between 50 um and 150 um. The MEMS device may be implemented as an inertial sensor among other applications.

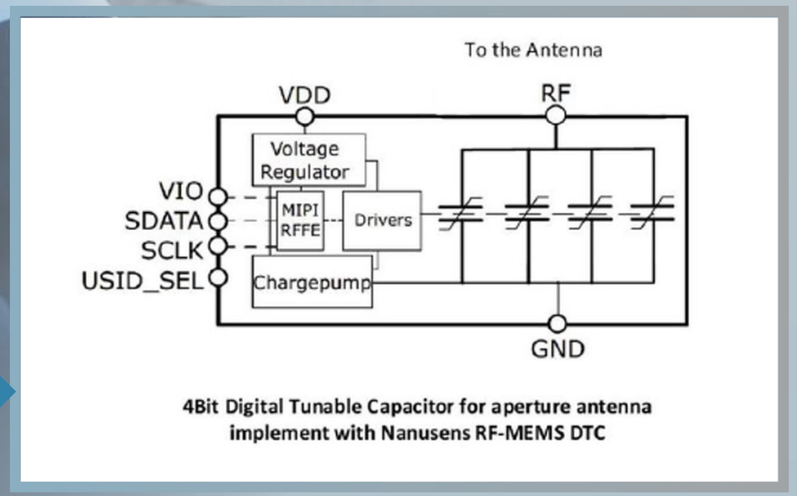
8 Claims, 9 Drawing Sheets

Nanusens first patent Granted Q2-2

RFDTC







e.MEMS TC (Tunable Capacitor)

> Initially targeting smartphone antenna tuning.

> Higherantennaefficiency in 5G & reduced PCB area.

> We are the only company providing a solution for 6G.

> Only company to satisfy all requirements: performance, cost, size, reliability & volume production capability.

TAM (Antenna Tuning)

> $1.2b smartphones sold per year, 400m phones are Tier 1

> 4 to 12 chips per phone, $0.5 ASP with gross margin +70%

> +$3b total market, +$800m Tier 1

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SILICON PHOTONICS

MRR

> **Power consumption**

100mW/lane (100Gbit/s) ⟶ 1pJ/bit. Equivalent to the optical link goal!

50m lanes/Hyperscaler, 500m lanes globally today, +1b lanes by 2030

⟶ 90MW power savings (90% power reduction)

78 tons of CO2 per year savings

> **Tuning Speed**

- No GPU idle waiting for synchronization

> **Thermal Cross talk**

- Higher WDM density

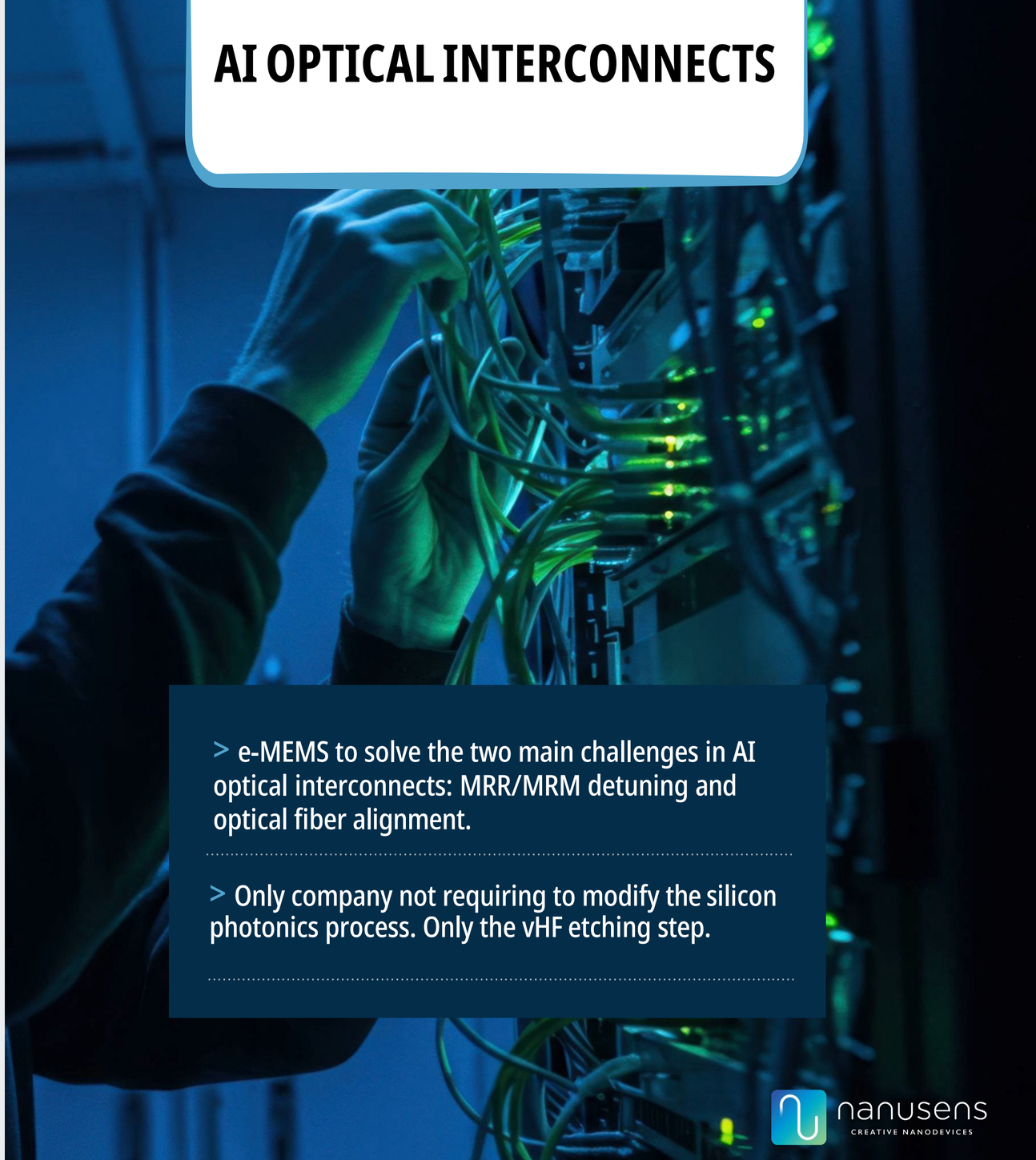
Very Precise Fiber Optical Alignment

> Automatic with leave behind MEMS built inside the Photonics IC.

> No need for any process change.

> Mechanically locked with no power applied after positioning.

AI OPTICAL INTERCONNECTS



> e-MEMS to solve the two main challenges in AI optical interconnects: MRR/MRM detuning and optical fiber alignment.

> Only company not requiring to modify the silicon photonics process. Only the vHF etching step.

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SILICON PHOTONICS MARKET POTENTIAL

> TAM

- Market size for silicon photonics AI interconnects (chips + modules): $2.3B (2025) to $17.8B (2034), CAGR 25.3%

> SAM

- $1 to $5 or more, per lane (100G)
- 400m optical lanes/year 2026, growing at +22% CAGR
- SAM ($1 per lane): $400m (2026), $1b (2030), $2b (2034)

OCI-MSA

FOUNDING MEMBERS

AMD · BROADCOM · Meta · Microsoft · NVIDIA · OpenAI

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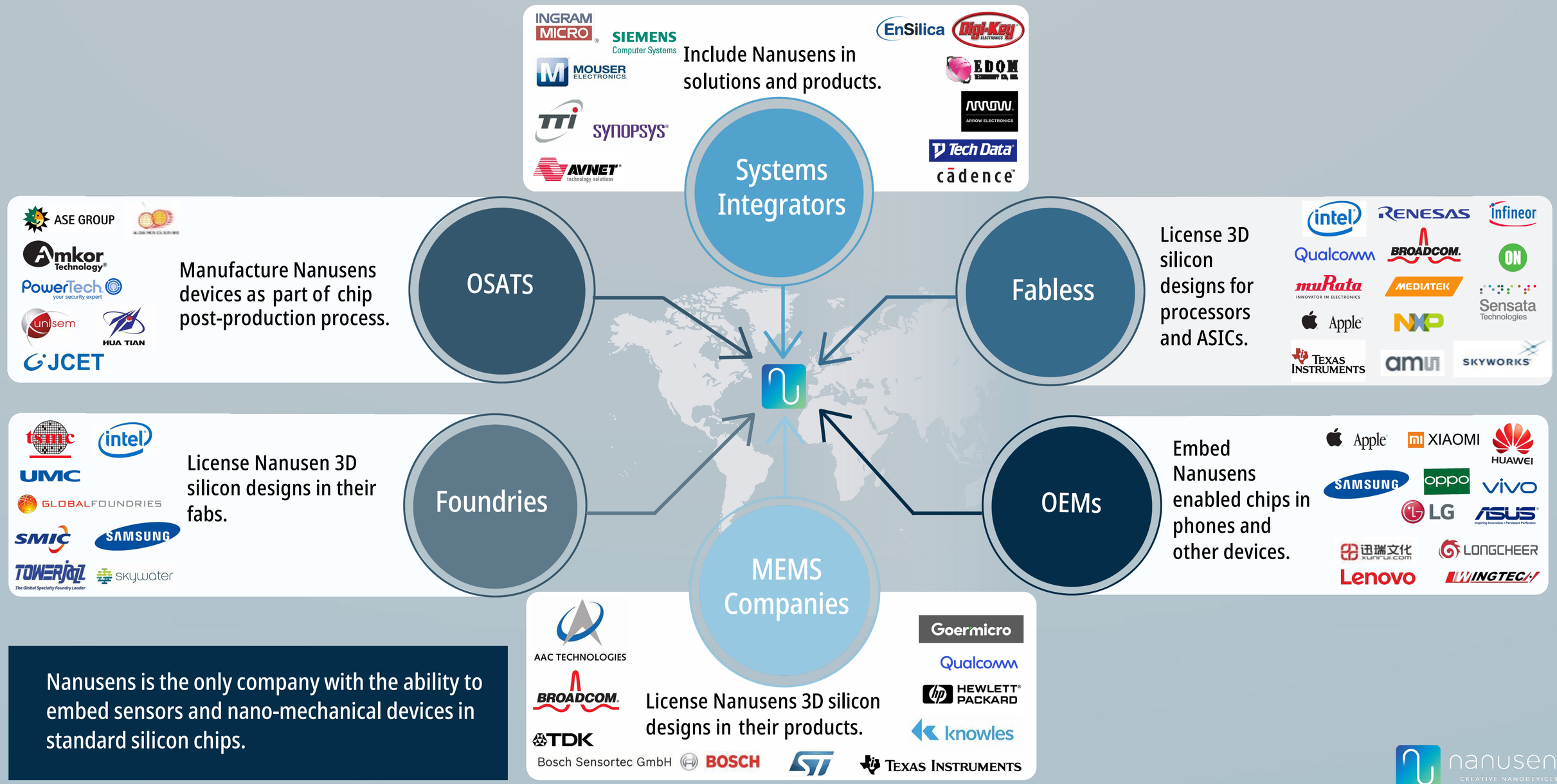
NANUSENS AT THE HEART OF THE SEMICONDUCTOR INDUSTRY

Strong IP protection will lead to global partnerships, licensing and royalty agreements



Nanusens is the only company with the ability to embed sensors and nano-mechanical devices in standard silicon chips.

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TEAM

Executive Team

Dr. Josep Montanyà
Chief Executive Officer - UK/ Spain

Co-founder leading the company, with +23 years of experience in MEMS, patents and the semiconductor industry. Founded Baolab Microsystems prior to Nanusens.

Núria Martí
Chief Financial Officer - UK

+15 years leading finance and operations, driving growth through strategic financial leadership. Economist specialised in tech companies and the arts sector. Former CFO at Linke (now Syntax).

Dr. Marc Llamas
Chief Technology Officer - Spain

Co-founder with +18 years in MEMS technology. Previously at Baolab Microsystems and DelfMems.

Dr. Tom Hanley
VP MEMS - UK

+12 years of experience in MEMS. Previously at Sofant Technologies and Cirrus Logic in senior MEMS engineering roles.

Board and Advisors

Ramon Borrell
Chairman - UK

+30 years in technical and business leadership positions in the field of MEMS inkjet printheads and applications. Previously at HP, Xaar, Quantica and as independent consultant.

Matthew Crowley
Board Director - USA

+22 years in MEMS, semiconductor, market and patents. Previously at Sand 9, Vesper and Qualcomm. Currently CEO at SCINTIL Photonics.

Filippos Kodellas
Board Director - UK

Tech VC founder and investor.
+15 years in the Special Situations community. Previously at Bain & Company, Houlihan Lokey, Sankaty Advisors, KKR, Tennor.

Richard Ord
Advisor - UK

+40 years in semiconductor industry: VLSI: $300m revenue, CSR sold to Qualcomm.

Yu-Ming Wang
Sr. Director, Engineering & Operations - Taiwan

+26 years focus on semiconductor manufacturing technology enablement and stable volume production. Previously in TSMC, KLA, specialty chemical / material companies, UMC, Allegro Microsystems, IGBT Startup, Nexperia and Vesper.

Dr. Graham Hine
Advisor - Commercial - UK

+30 years experience in semiconductor technology and business. Serial CEO, Chairman of deep tech start-ups. Previously at Philips, Hitachi, Capteur, P2i, Hardide, SGX.

Sandhiprakash Bhide
Board Advisor - USA

+20 years with Intel Steering committee, Edison Awards Multiple patents.

Jeff Hilbert
Board Advisor - USA

+50 years in technology companies with annual budgets between $50M and $150M. 2 exits. WiSpry, an RF-MEMS company. Raised over $150M in startup funding.

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REVENUE FORECAST

- NRE Revenue starting in 2026
- Product sales revenues starting from 2028
- Licensing revenues kick-in for each product before launch
- Royalty revenues to semiconductor companies from 2035 and to Foundries from 2038
- Margins 60% on product sales; 90%+ on royalties

Financial Projections (approx.)

	2026	2027	2028	2029	2030	2031	2032	2033	2034
Revenue (*)	£0.3 M	£0.6 M	£0.98 M	£2.15 M	£54.67 M	£150.69 M	£433.45 M	£793.66 M	£1,216 M
Production Cost	£0	£0	£0	£0.75 M	£21.45 M	£59.34 M	£170.84 M	£312.71 M	£480.09 M
GROSS PROFIT	£0.3 M	£0.6 M	£0.98 M	£1.40 M	£33.21 M	£91.35 M	£262.61 M	£480.96 M	£736.02 M
GROSS Margin %	100%	100%	100%	65%	61%	61%	61%	61%	61%
OPEX	£2.87 M	£2.59 M	£3.10 M	£3.74 M	£6.05 M	£11.13 M	£16.06 M	£20.96 M	£30.15 M
EBITDA	-£2.42 M	-£1.54 M	-£1.81 M	-£1.97 M	£27.45 M	£80.72 M	£247.73 M	£461.82 M	£708.07 M
EBITDA Margin %	-	-	-	-	50%	54%	57%	58%	58%

(*) Revenues in 2027 and 2028 derive from IP royalties related tothe ESD product.
EBITDA includes non-dilutivegrants (not shown separately in the table).
All figures converted from EUR to GBP at a fixed exchange rate of 1 EUR = 0.86 GBP.

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INVEST IN THE NEXT REVOLUTION IN SEMICONDUCTOR & SILICON PHOTONICS DESIGN

- $8m (£6m) in exchange of 20% Equity
  - Finalize first product
  - Design win
  - Series A
- Proven Technology
- Blocking patent portfolio
- Finishing first product & clear route to market
- Discussing formal engagement with major RF corporation
- Approaching main AI chip vendors and suppliers to provide our silicon photonics IP
- Excellent Team, Board of Directors and Advisors Network
- Exit: trade sale or IPO

For more information contact:
josep.montanya@nanusens.com

Scan to learn more

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